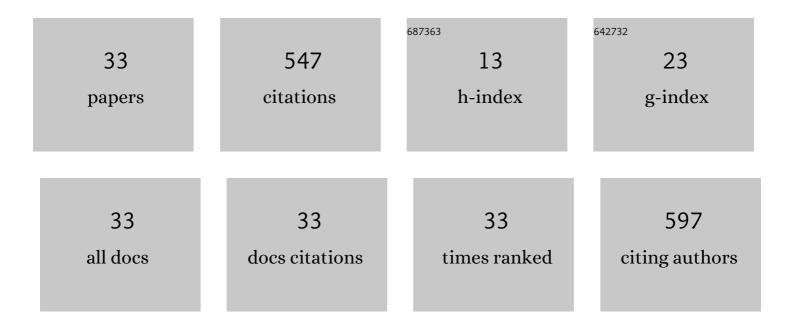
Jun'ichi Kanasaki

List of Publications by Year in descending order

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ΙΠΝΊCΗΙ ΚΑΝΑSAΚΙ

#	Article	IF	CITATIONS
1	Formation of <mml:math <br="" xmlns:mml="http://www.w3.org/1998/Math/MathML">display="inline"><mml:mi>s</mml:mi><mml:msup><mml:mi>p</mml:mi><mml:mn>3</mml:mn>Carbon Nanostructures by Femtosecond Laser Excitation of Graphite. Physical Review Letters, 2009, 102 087402</mml:msup></mml:math>	p> <td>th>-Bonded</td>	th>-Bonded
2	102_087402 Ultrafast relaxation of highly excited hot electrons in Si: Roles of the <mml:math xmlns:mml="http://www.w3.org/1998/Math/MathML" display="inline" > <mml:mrow> <mml:mi mathvariant="normal" > L < /mml:mi > <mml:mo> a^ <mml:mi mathvariant="normal" > X < /mml:mi > </mml:mi </mml:mo></mml:mi </mml:mrow> intervalley scattering. Physical Review B, 2011, 84, .</mml:math 	3.2	38
3	Primary Processes of Laser-Induced Selective Dimer-Layer Removal onSi(001)â^'(2×1). Physical Review Letters, 2002, 89, 257601.	7.8	37
4	Imaging Energy-, Momentum-, and Time-Resolved Distributions of Photoinjected Hot Electrons in GaAs. Physical Review Letters, 2014, 113, 237401.	7.8	37
5	Formation of hot-electron ensembles quasiequilibrated in momentum space by ultrafast momentum scattering of highly excited hot electrons photoinjected into the Γ valley of GaAs. Physical Review B, 2016, 93, .	3.2	37
6	Laser-induced bond breaking of the adatoms of the Si(111)-7 × 7 surface. Surface Science, 1996, 349, L153-L158.	1.9	25
7	Ultrafast scattering processes of hot electrons in InSb studied by time- and angle-resolved photoemission spectroscopy. Physical Review B, 2015, 91, .	3.2	25
8	Site-sensitive yield of atomic emission induced by laser irradiation on Si(111)â^7Ă—7 surface. Solid State Communications, 1996, 98, 913-916.	1.9	22
9	Laser-Induced Electronic Emissions of Si Atoms from Si(100) Surfaces. Japanese Journal of Applied Physics, 1993, 32, L859-L862.	1.5	19
10	Role of applied bias and tip electronic structure in the scanning tunneling microscopy imaging of highly oriented pyrolytic graphite. Physical Review B, 2012, 85, .	3.2	18
11	Photoinduced Structural Instability of the InP(110)â^'(1×1)Surface. Physical Review Letters, 2004, 93, 117401.	7.8	17
12	Laser-induced electronic desorption from InP surfaces studied by femtosecond nonresonant ionization spectroscopy. Physical Review B, 2001, 64, .	3.2	16
13	Energy relaxation mechanism of hot-electron ensembles in GaAs: Theoretical and experimental study of its temperature dependence. Physical Review B, 2018, 97, .	3.2	16
14	Laser-induced electronic desorption of Si atoms fromSi(111)â^'(7×7). Physical Review B, 2002, 66, .	3.2	13
15	Ultrafast relaxation dynamics of highly excited hot electrons in silicon. Physical Review B, 2019, 100, .	3.2	13
16	Defect initiated particle emission from semiconductor surfaces by laser irradiation. Surface Science, 1993, 283, 169-176.	1.9	11
17	Two-hole localization mechanism for electronic bond rupture of surface atoms by laser-induced valence excitation of semiconductors. Physical Review B, 2006, 74, .	3.2	11
18	Fermi-level dependent morphology in photoinduced bond breaking on (110) surfaces of Ill–V semiconductors. Surface Science, 2007, 601, 2367-2372.	1.9	9

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#	Article	IF	CITATIONS
19	Ultrafast relaxation of photoinjected nonthermal electrons in the Γ valley of GaAs studied by time- and angle-resolved photoemission spectroscopy. Physical Review B, 2021, 104, .	3.2	8
20	The DIET from semiconductor surfaces by excitation of valence electrons. Nuclear Instruments & Methods in Physics Research B, 1995, 101, 93-102.	1.4	7
21	Defect-initiated atomic emissions from semiconductor surfaces induced by laser irradiation: electronic cleaning of defects on surfaces. Applied Surface Science, 1994, 79-80, 100-103.	6.1	6
22	Ultrafast dynamics in photoexcited valence-band states of Si studied by time- and angle-resolved photoemission spectroscopy of bulk direct transitions. Physical Review B, 2018, 97, .	3.2	6
23	Intact-sheet double-layer ablation induced by femtosecond-laser excitation of graphite. Surface Science, 2011, 605, 1497-1502.	1.9	4
24	Low energy laser photoelectron study of defect states on cleaved Si(111)2 × 1 surfaces. Surface Science, 1996, 349, L107-L110.	1.9	3
25	Photon energy dependence of the laser-induced emission yield of Si atoms from the Si(100) surface. Journal of Physics Condensed Matter, 1996, 8, 1475-1484.	1.8	3
26	<title>Laser-induced electronic bond breaking and structural changes on semiconductor surfaces</title> . , 1999, , .		3
27	Electronic bond rupture of Si atoms on Si()-(2×1) induced by 1.16-eV photon excitation. Surface Science, 2003, 528, 115-120.	1.9	3
28	Comparison of Electronic-Excitation-Induced Structural Modification of Carbon-Based Nanomaterials with that of Semiconductor Surfaces. Nano, 2016, 11, 1630001.	1.0	2
29	Electronic structure of the surface unoccupied band of Ge(001)- <mml:math xmlns:mml="http://www.w3.org/1998/Math/MathML"> <mml:mrow> <mml:mi>c</mml:mi> <mml:mo> (: Direct imaging of surface electron relaxation pathways. Physical Review B, 2017, 96, .</mml:mo></mml:mrow></mml:math)> < a anl:m	ın> 4
30	Enhancement of Emission of Si Atoms from Si(100) Surface by Low-Rate Br Exposure: A New Model of Dry Etching Based on Defect-Adsorbate Interaction. Japanese Journal of Applied Physics, 1994, 33, 2255-2257.	1.5	1
31	Laser-induced bond breaking and structural changes on Si(111)-7×7 surfaces. Applied Surface Science, 1998, 127-129, 33-39.	6.1	1
32	<title>Laser-induced electronic desorption and structural changes on Si(001)-(2x1)</title> ., 2002, , .		1
33	Crucial roles of holes in electronic bond rupture on semiconductor surfaces. Surface Science, 2014, 626, 49-52.	1.9	1